#### SPIN-DEPENDENT TUNNELING CHARACTERISTICS OF Co<sub>2</sub>MnGe-BASED MAGNETIC TUNNEL JUNCTIONS

William Love<sup>1,2</sup>, Tomoyuki Taira<sup>2</sup>, Masafumi Yamamoto<sup>2</sup>

- NanoJapan Program, Rice University and Department of Physics, Virginia Polytechnic Institute & State University
  - 2. Division of Electronics for Informatics, Graduate School of Information Science and Technology, Hokkaido University, Sapporo, Japan

Manipulation of the spin degree of freedom of the conduction electron in an electron device, or spintronics, has been extensively studied recently. Half-metallic ferromagnets (HMFs) feature an energy gap for one spin direction (mostly the minority-spin band) at the Fermi level  $(E_{\rm F})$ , which provides complete spin polarization at  $E_{\rm F}$  making HMFs one of the key materials for ferromagnetic electrodes in spintronic devices. Co-based Heusler alloys (Co<sub>2</sub>YZ) are amongst the most extensively studied potentially half-metallic electrode materials due to the half metallicity theoretically predicted for several of these alloys and because of their high Curie temperatures, which are well above room temperature. Our purpose in this study was to investigate the spin-dependent tunneling characteristics of Co<sub>2</sub>MnGe/MgO/Co<sub>2</sub>MnGe magnetic tunnel junctions (MTJs) fabricated as a function of Mn compositions α for Co<sub>2</sub>Mn<sub>α</sub>Ge and to understand the origin of the observed dependence in terms of the effect of defects possibly associated with non-stoichiometry in prepared Co<sub>2</sub>MnGe electrodes. We fabricated Co<sub>2</sub>MnGe/MgO/Co<sub>2</sub>MnGe by co-sputtering from a Co<sub>2</sub>MnGe target and a Mn target for both the lower and upper Co<sub>2</sub>MnGe electrodes. Through the use of co-sputtering, we were able to precisely control the Mn composition α in the Co<sub>2</sub>Mn<sub>α</sub>Ge electrodes. The tunnel magnetoresistance (TMR) ratios at both 4.2 K and room temperature increased systematically with increasing α in the Co<sub>2</sub>Mn<sub>α</sub>Ge electrodes, which indicates the TMR ratio is explicitly dependent on the Mn composition. The observed lower TMR ratio for MTJs with Mn-deficient Co<sub>2</sub>MnGe electrodes is explained by the existence of Co<sub>Mn</sub> antisites, where a Mn site is replaced by a Co atom.  $Co_{Mn}$  antisites result in the appearance of minority-spin gap states around  $E_F$  and thereby leads to the increased tunnel conductance for the antiparallel (AP) state. On the other hand, the observed higher TMR ratio for MTJs with Mn-rich Co<sub>2</sub>MnGe electrodes is explained by the suppressed Co<sub>Mn</sub> antisites, which results in the decreased density of minority-spin gap states around  $E_{\rm F}$  and thereby leads to the decreased tunnel conductance for AP. Our experimental findings suggest that the density of minority-spin gap states can be reduced by appropriately controlling the defects in Co<sub>2</sub>MnGe electrodes.





# Spin-Dependent Tunneling Characteristics of Co<sub>2</sub>MnGe-based Magnetic Tunnel Junctions

William Love<sup>1,2</sup>, Tomoyuki Taira<sup>2</sup>, Masafumi Yamamoto<sup>2</sup>

1. NanoJapan Program, Rice University and Department of Physics, Virginia Polytechnic Institute & State University

Division of Electropics for Informatics, Graduate School of Information Science and Technology, Hokkaido University

2. Division of Electronics for Informatics, Graduate School of Information Science and Technology, Hokkaido University, Sapporo, Japan



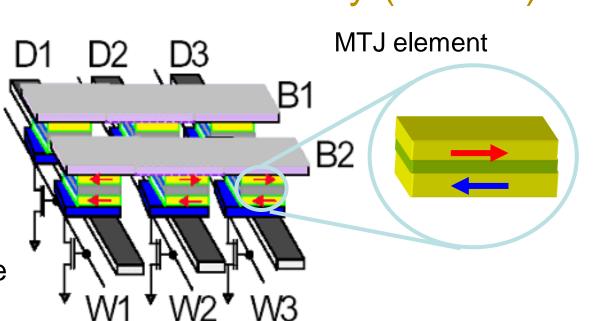


#### Introduction

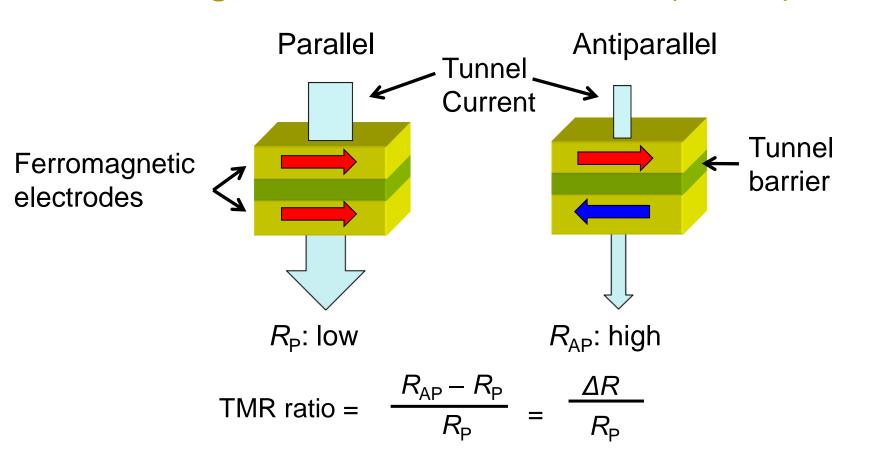
#### Magnetoresistive Random Access Memory (MRAM)

#### MRAM characteristics:

- ► Non-volatile
- ► High speed read/write
- ► High density
- ► Unlimited read/write endurance



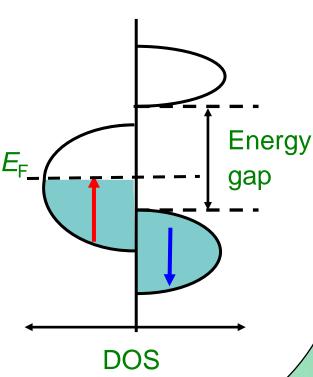
## Magnetic Tunnel Junctions (MTJs)



► High TMR ratios in MTJs are necessary in order for constructing high-speed MRAMs with large-scale-integration.

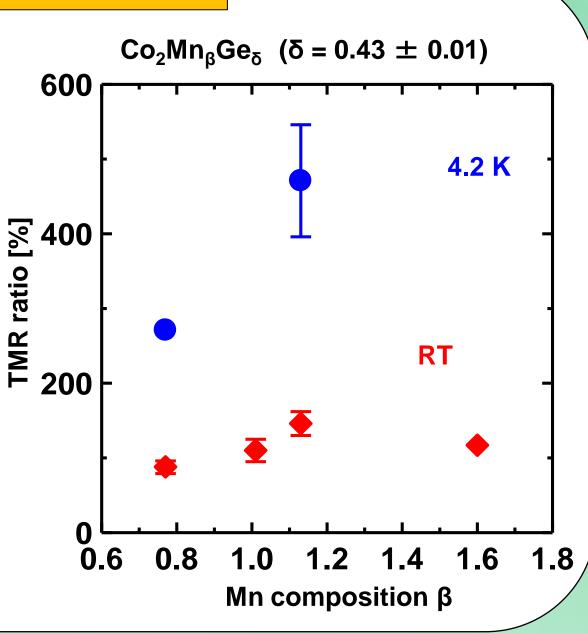
#### Heusler Alloys

- ► Heusler alloys are theoretically predicted to be half-metals.
- ► They have high Curie temperatures which are well above room temperature.
- Co₂MnGe was chosen for the MTJ electrodes due to its small lattice mismatch of -3.6% with MgO for a 45° inplane rotation with the (001) plane.

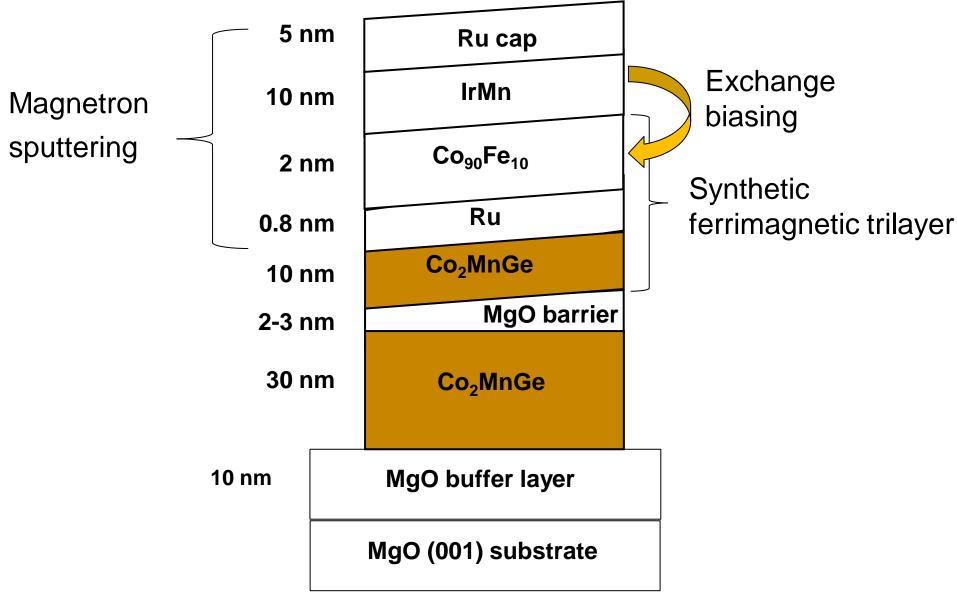


## Purpose

- ► There is an increasing TMR ratio for increasing Mn composition β from 0.77 to 1.13 at RT.
- Investigate the spin–dependent tunneling characteristics of  $Co_2MnGe/MgO/Co_2MnGe\ MTJs$  fabricated as a function of Mn compositions β for  $Co_2Mn_βGe_δ$  at 4.2 K. 200
- ► Understand the origin of the observed dependence associated with nonstoichiometry in prepared Co<sub>2</sub>MnGe electrodes.

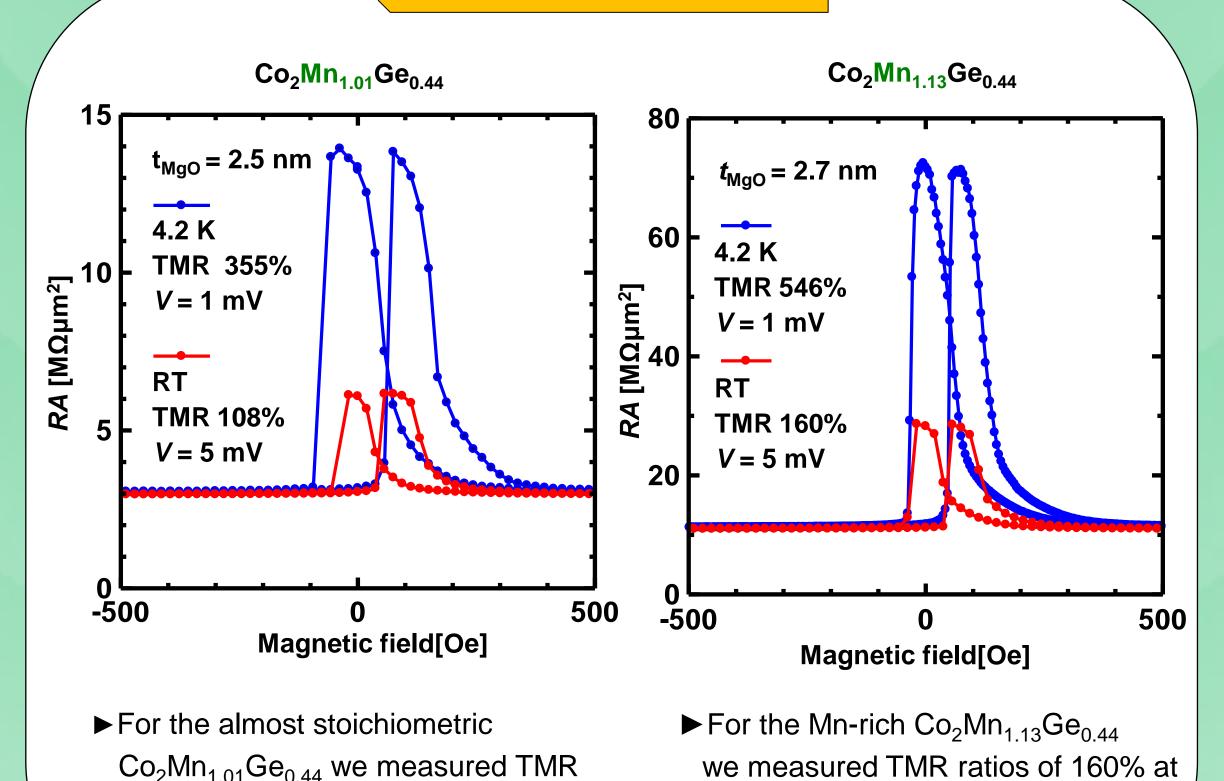


## Layer Structure



- ► All of the layers were deposited in an ultrahigh vacuum chamber (~8 x10<sup>-8</sup> Pa).
- ► The CMG layers were deposited by co-sputtering from a Co₂MnGe target and a Mn target in order to precisely control the Mn composition β in the Co₂MnβGe electrodes.
- ► Immediately after being deposited, both the upper and lower CMG electrodes were annealed *in situ* at 500° C for 15 minuets.
- ► Epitaxial growth for all layers was confirmed from RHEED observations.
- ► The MTJs were fabricated using photolithography and argon ion milling.

### Results



RT and 546% at 4.2 K.

ratios of 108% at RT and 355% at 4.2 K.

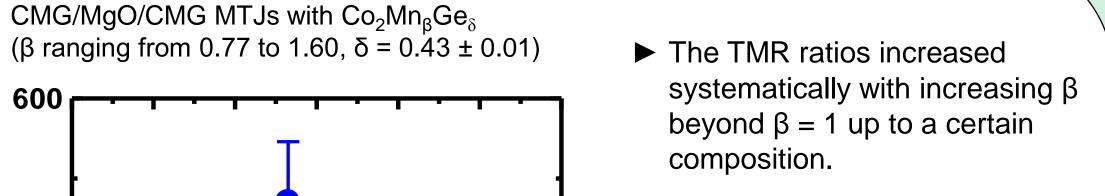
## Results cont.

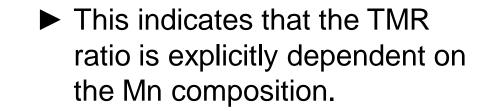
4.2 K

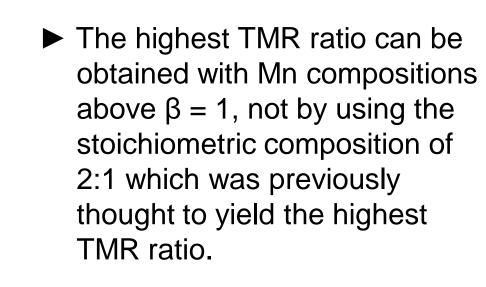
0.6 0.8 1.0 1.2 1.4 1.6 1.8

Mn composition  $\beta$ 

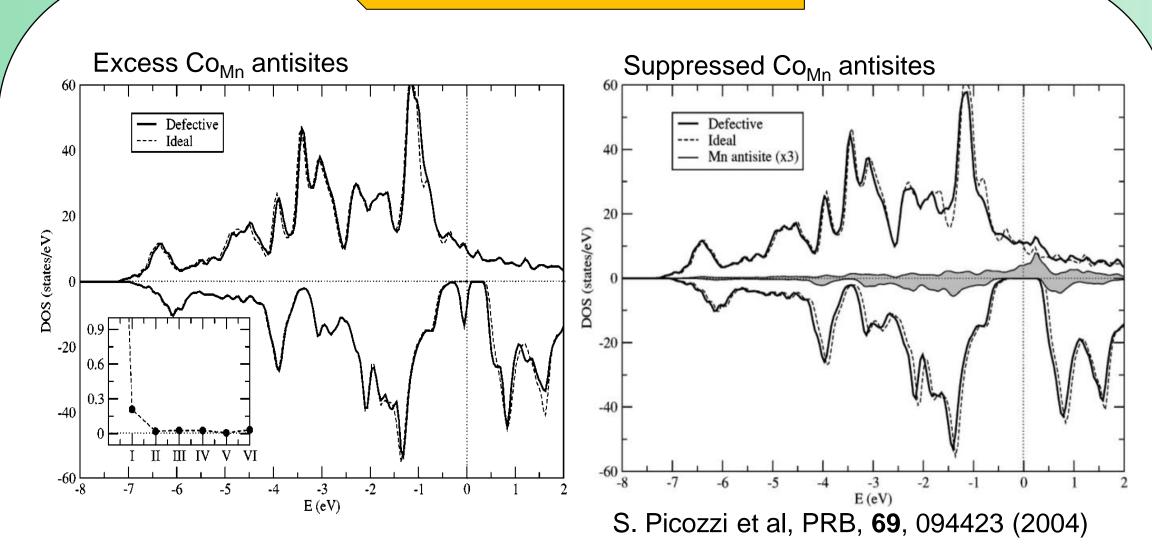
≝ 200







# Discussion



- ► Co<sub>Mn</sub> antisites, which induce minority spin gap states at the Fermi level, formed in Mn deficient Co<sub>2</sub>MnGe films leading to lower TMR ratios.
- Conversely, in Mn rich Co₂MnGe films, there was a suppression of Co<sub>Mn</sub> antisites which lead to an increase in the TMR ratios.

#### Conclusion

- ► Higher TMR ratios were obtained from MTJs with Mn-rich CMG electrodes.
- ► The density of minority-spin gap states can be reduced by appropriately controlling defects in Co<sub>2</sub>MnGe electrodes.

# Acknowledgments

Research conducted at Hokkaido University as a participant in the Rice University NanoJapan 2009 program sponsored by the National Science Foundation under Grant No. OISE-0530220.

